



F.J. Ferrer, A. Fernández, Joao Cruz, J.P. Fernández-García, D. Hufschmidt, B. Fernández-Martínez



## **INDEX**



## Targets

- Helium targets problems
- Sample preparation
- Morphological characterization
- Elemental characterization
- Cross section measurements
  - Results: <sup>3</sup>He(<sup>1</sup>H,<sup>1</sup>H)<sup>3</sup>He Elastic scattering (Backscattering, θ>90°)
  - Perspectives: Next future
- Conclusions







Using nuclear reactions for investigating properties of nuclei far from the stability line ("exotic" nuclei).

FERRER CAPN 2023FERRER **UAStable exotic** nucleus

> exotic nucleus = projectil H or He = target

## INVERSE KINEMATIC





Protons		Alphas		
( <sup>1</sup> H, <sup>1</sup> H)	Elastic so	( <sup>4</sup> He, <sup>4</sup> He)		
( <sup>1</sup> H, <sup>3</sup> H)	Tw neutron	( <sup>4</sup> He, <sup>6</sup> He)		
(¹H, ⁵H)	Four neutron transfer		(⁴He, <sup>8</sup> He)	

## He problems

Gas jet target



polyethylene (CH<sub>2</sub>)n Protons GAS, no solid molecules Alphas (Helium) Gas cell Image from K.E. Rehm, et al., Nucl. Instr. and Meth. Phys. Res. A, 647, (2011) 3-9.

Image from Oak Ridge National Laboratory web page

#### Implanted target foils



Image from Shellback Semiconductors Technology webpage

## Filling the chamber







#### SOLID TARGETS

## Homogeneously distributed pores structure





## 10x10x0,5 mm<sup>3</sup> target



## Sample preparation Magnetron Sputtering



#### Adjustable parameters:

- RF/DC Power
- Substrate bias
- Gas type and Pressure
- Target material



#### Magnetron sputtering:

- Wide extended technique in industry
- Very versatile allowing to deposit on large areas
- Deposition on different kinds of substrates like glass or even sensible and flexible like polymers
- Controlling deposition parameters is possible to control the microstructure and composition

Dynamic flux conditions High gas consumption 几

very EXPENSIVE for <sup>3</sup>He (100s \$/l)



nmalu U

Α quasistatic procedure has been developed at the Materials Science Institute in Seville (ICMS-CSIC) [WO/2020/099695] to carry out the magnetron sputtering deposition procedure under the conditions of a very consumption of the low working gas.



Figure from A. Fernández et al. Mater. Des., 186 (2020), p. 108337

> L International Meeting on Fundamental Physics and XV CPAN Days 2-6 October 2023



DRASTIC REDUCTION (>99.5%) OF THE GAS CONSUMPTION

# Morphological Characterization SEM and TEM









Homogeneously distributed pores structure



10x10x0,5 mm<sup>3</sup> target

L International Meeting on Fundamental Physics and XV CPAN Days 2 - 6 October 2023





7/15 TEM cross-sectional view

## **Elemental Characterization**

## Proton Elastic Backscattering Spectroscopy





**Energy (keV)** SIMNRA software and Langley cross section

## High amount of He!!! <sup>3</sup>He/Si = 0,20

Sample	thickness (10 <sup>15</sup> at/cm²)	Au (%at)	Si (%at)	<sup>3</sup> He (%at)	Au (μg/cm²)	Si (µg/cm²)	<sup>3</sup> He (μg/cm²)
1st layer	30,0 ± 1,5	100			8,92 ± 0,45		
2nd layer	5300 ± 250		82,6 ± 1,1	17,3 ± 0,8		204,5 ± 10,2	4,48 ± 0,25







## <sup>3</sup>He(<sup>1</sup>H,<sup>1</sup>H) <sup>3</sup>He Elastic scattering

Backscattering ( $\theta > 90^\circ$ )





## <sup>3</sup>He(<sup>1</sup>H,<sup>1</sup>H) <sup>3</sup>He Elastic scattering Backscattering (θ > 90°)



#### PRELIMINARY RESULTS



## **Perspectives: Next future**

Tailoring of the targets depending on the used proton energy.



Testing self-supported targets (as <sup>4</sup>He targets); forward scattering







## nmalu U Lisboa

#### **Perspectives: Next future**

Lower Energy (E < 500 keV) Rutherford contribution Cross Section

#### Higher Energy (E > 6000 keV) Possible decrease of the Cross Section







#### **Perspectives: Next future**





## **CONCLUSIONS**



- The H+<sup>3</sup>He reaction at energies between 1,5 and 5,5 MeV at different angles using a <sup>3</sup>He solid target was measured for the first time at CNA.
- The measured differential cross sections are in good agreement with the only results of found in literature (Langley).
- The specially prepared Si-<sup>3</sup>He thin solid film has demonstrated its capability as a suitable target for experimental studies on nuclear reactions involving <sup>3</sup>He targets.



## Some bibliography



- "Novel solid 4He targets for experimental studies on nuclear reactions: 6Li+4He differential cross-section measurement at incident energy of 5.5 MeV", F.J. Ferrer, B. Fernández, J.P. Fernández-García, F.G. Barba, A. Fernández, D. Galaviz, V. Godinho, J. Gómez-Camacho, A.M. Sánchez-Benítez, Eur. Phys. J. Plus 135 (2020) 465 (1-8).
- "Characterization and validation of a-Si magnetron sputtered thin films as solid He target with high stability for nuclear reactions", V Godinho, F. Ferrer, B. Fernández, J. Caballero-Hernandez, J. Gómez-Camacho, A. Fernández, ACS Omega, 1 (2016) 1229–1238.
- "Low gas consumption fabrication of 3He solid targets for nuclear reactions", A. Fernández, D. Hufschmidt, J.L. Colaux, J.J. Valiente-Dobón, V. Godinho, M.C. Jiménez de Haro, D. Feria, A. Gadea, S. Lucas, Mater. Des., 186 (2020) 108337
- "Method for obtaining a solid material with gaseous aggregates by means of magnetron cathode sputtering in static or quasistatic conditions to reduce the use of gas", A. Fernández, D. Hufschmidt, V. Godinho, M.C. Jiménez de Haro, ,2020, Patent WO2020099695A1
- Solid target of noble gases for nuclear reactions", V. Godinho, J. Caballero, A. Fernández, F.J. Ferrer, J.Gómez-Camacho, B. Fernández-Martínez, 2017, Patent W02017207848A1
  Linternational Meeting







# Thank you for your attention



